

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Hsiao, Tommy C.; Hui, Angela T.; Ogle, Robert B.; Pham, Tuan Duc;  
Plat, Marina V.; Ramsbey, Mark T.; Shen, Lewis  
Assignee: Advanced Micro Devices, Inc.  
Title: Polished Flash Process With Metal Gates And Improved Planarity  
Serial No.: 09/430,366 Filing Date: October 28, 1999  
Examiner: J. Chen Group Art Unit: 2813  
Docket No.: M-7523 US



San Jose, California  
January 16, 2001

COMMISSIONER FOR PATENTS  
Washington, D. C. 20231

**PETITION FOR EXTENSION OF TIME**

Dear Sir:

Applicants respectfully petition for a (3) month extension of time within which to respond to the July 17, 2000 outstanding Office Action, such extension allowing the undersigned until January 17, 2001 to respond.

Please charge the amount of \$890.00 as set forth in the enclosed transmittal letter.

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on Jan 16, 2001.

Attorney for Applicants

Date of Signature

Respectfully submitted,

Edward C. Kwok  
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